

What is claimed is:

1. A chuck equipment comprising
a plate-shaped base,
a first electrode to which a first voltage is applied,
5 and
a second electrode to which a second voltage
different from the first voltage in magnitude is applied,
the first and second electrodes being insulated from each
other and arranged on a surface of said base.
- 10 2. The chuck equipment according to claim 1, wherein
said surfaces of said first and second electrodes are
exposed.
3. The chuck equipment according to claim 2, wherein
the chuck equipment is constructed in such a manner that a
15 substrate is placed on the surface of said chuck equipment
on which said first and second electrodes are arranged to
cause said substrate to be brought into contact with said
first and second electrodes.
4. The chuck equipment according to claim 2, wherein
20 the surface of said base is flush with the surfaces of said
first and second electrodes.
5. The chuck equipment according to claim 2, wherein
an insulating convexity portion is arranged between said
first and second electrodes.
- 25 6. The chuck equipment according to claim 2, wherein

electric field of 1.0×10^6 V/m or greater between said first and second electrodes.

14. The vacuum processing apparatus according to claim 13, wherein a protective plate is arranged around said chuck equipment, and the vacuum processing apparatus is constructed in such a manner that a substrate is placed on said chuck equipment to cause said substrate to be accommodated in said protective plate.